

PATENT APPLICATION

Technology Center 2100

IN THE UNITED STATES PATENT AND	TR	ADEMARK OFFICE
In re Application of:)	
	:	Examiner: P. L. Rodriguez
Keiji EMOTO)	6/15
	:	Group Art Unit: 2125
Application No.: 09/833,766)	
	:	Confirmation No.: 4154
Filed: April 13, 2001)	
	:	
For: PIPE STRUCTURE, ALIGNMENT APPARATUS,)	June 2, 2004
ELECTRON BEAM LITHOGRAPHY	:	
APPARATUS, EXPOSURE APPARATUS,)	
EXPOSURE APPARATUS MAINTENANCE	:	חבסבוו/בח
METHOD, SEMICONDUCTOR DEVICE)	RECEIVED
MANUFACTURING METHOD, AND SEMI-	:	UIN 0 7 2004
CONDUCTOR MANUFACTURING FACTORY)	JUN 0 7 2004

Mail Stop RCE

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

PRELIMINARY AMENDMENT

Sir:

Prior to further examination on the merits, please amend the above-identified application as follows: